

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of
KOBAYASHI, S.

Atty. Ref.: 900-471

Serial No. To be assigned

Group:

Filed: August 4, 2003

Examiner:

For: MASK PATTERN AND METHOD FOR FORMING RESIST
PATTERN USING MASK PATTERN THEREOF

* * * * *

August 4, 2003

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:


INFORMATION DISCLOSURE STATEMENT

As suggested by 37 C.F.R. 1.97, the undersigned attorney brings to the attention of the Patent and Trademark Office the references listed on the attached form PTO-1449, a copy of each of which is enclosed. This is not to be construed as a representation that a search has been made or that no better prior art exists, or that a reference is relevant merely because cited.

The Examiner is requested to initial the attached form PTO-1449 and to return a copy of the initialed document to the undersigned as an indication that the attached references have been considered and made of record.

Respectfully submitted,

NIXON & VANDERHYE P.C.

By: 
H. Warren Burnam, Jr.
Reg. No. 29,366

HWB:ecb
1100 North Glebe Road, 8th Floor
Arlington, VA 22201-4714
Telephone: (703) 816-4000
Facsimile: (703) 816-4100

INFORMATION DISCLOSURE
CITATION

ATTY. DOCKET NO.

SERIAL NO.

900-471

To be assigned

APPLICANT

KOBAYASHI, S.

(Use several sheets if necessary)

FILING DATE

GROUP

August 4, 2003

U.S. PATENT DOCUMENTS

[illegible]

FOREIGN PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS							TRANSLATION	
DOCUMENT			DATE	COUNTRY	CLASS	SUBCLASS	YES	NO
		3-201422	09/1991	JP			x	
		4-267537	09/1992	JP			x	
		4-273427	09/1992	JP			x	
		4-355910	12/1992	JP			x	

OTHER DOCUMENTS (including Author, Title, Date, Pertinent pages, etc.)

[illegible]

*Examiner

Date Considered

Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to application.